

03500.014776.



PATENT APPLICATION

1771

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
HIROKATSU MIYATA) Examiner: VO, HAI
Application No.: 09/657,616) Group Art Unit: 1771
Filed: September 8, 2000)
For: MESOSTRUCTURED THIN FILM,)
MESOPOROUS THIN FILM, AND)
PROCESS FOR PRODUCTION)
THEREOF) June 12, 2002

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Commissioner for Patents
Washington, D.C. 20231

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RESPONSE TO RESTRICTION REQUIREMENT

Sir:

This is in response to the Office Action dated May 22, 2002, imposing a restriction requirement in the above-identified application.

REMARKS

The Examiner has required restriction between the inventions of groups I and II as follows:

Group I: Claims 1-22, drawn to a process of making a mesostructured thin film, classified in class 423, subclass various.

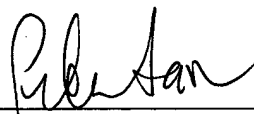
Group II: Claims 23-36, drawn to a mesostructured thin film, classified in class 428, subclass 304.4+.

Applicants hereby provisionally elect Group II, Claims 23-36, with traverse.

The process claims of Group I include the step of producing a structure having rod-like pores on a polymer compound. The process cannot be used for products other than those claimed in Group II directed to a thin film.

Applicants' undersigned attorney may be reached in our New York office by telephone at (212) 218-2100. All correspondence should continue to be directed to our below listed address.

Respectfully submitted,



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